



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of  
Inventor(s): Mills

Group Art Unit: 1745

Appln. Ser. No.: 09/501,622

Secret Committee: Kalafut *for the*  
*Secret Committee*

Filing Date: 02/09/2000

Title: DOPED SEMICONDUCTOR AND METHOD OF MAKING THE DOPED  
SEMICONDUCTOR

\* \* \* \*

February 23, 2006

**SUPPLEMENTAL RESPONSE TO FINAL OFFICE ACTION MAILED  
JANUARY 26, 2005 AND REQUEST FOR CONTINUED EXAMINATION**

Commissioner of Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant files this supplemental response to the Final Office Action mailed January 26, 2005. Please also consider this paper as a Petition for a five-month extension of time and Request for Continued Examination.

Claims 1-265 are pending in the present application.

Submitted with this response is new, non-cumulative scientific evidence further demonstrating the existence of lower energy states of hydrogen in a number of different ways, including, but not limited to, studies of spectroscopic lines, energy output, compositions of matter, generated plasmas, and inverted hydrogen populations. As detailed below, Applicant also identifies independent third-party data pursuant to the PTO's agreement, which evidence resulted in verbal confirmation by Examiner Wayne Langel that two BlackLight applications formally handled by him were allowable before he was told to misrepresent that fact and, thus, was forced to resign from examining those cases "for moral and ethical reasons."